



k-resolved electronic structure by soft-X-ray ARPES: From 3D systems to buried heterostructures

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Outline

- 1.Why (and why not) ARPES in the soft-X-ray range?
- probing depth, 3D momentum resolution and resonant photoemission
- 2. Instrumentation
- 3. Spectroscopic abilities of SX-ARPES and results
- from 3D electronic structure to buried heterostructures and impurities

Why Soft-X-Ray ARPES (*hv* ~ 500-1500 eV)?

Virtue 1: Increasing λ

increasing bulk sensitivity
buried impurities, interfaces and heterostructures



\Rightarrow Virtue 2: Improving *intrinsic resolution* $\Delta k_z = \lambda^{-1}$

- reduction of Δk_z broadening
- sharply defined 3D k-vector
- combination with free-electron final states \Rightarrow 3D materials



Virtue 3: Elemental specificity through resonant photoemission

• combination with increasing $\lambda \Rightarrow$ buried interfaces, heterostructures and impurities

Further virtues: Regular atomic-like matrix elements ...

Challenges of SX-ARPES

- ΔE of a few tens meV (vs a few meV in VUV-ARPES)
- *e-ph* scattering destructive for **k**-resolution (photoelectron wavelength ~ thermal motion):

$$I^{coh} = W(T)I_{T=0}^{coh}$$

(W(T) = exp($-\Delta G^2 U_0^2(T)$), with $\Delta G^2 \propto E$ and $U_0^2 \propto T$)
- liquid-He cooling

loss of photoexcitation cross-section by 2-3 orders of magnitude
efficient detectors and high photon flux instrumentation



ADRESS (ADvanced RESonant Spectroscopies) Beamline at SLS



- RIXS (Resonant Inelastic X-ray scattering) and ARPES endstations
- soft-X-ray radiation with circular and 0-180° variable linear polarizations
- energy range 300 1600 eV
- high resolution $\Delta E \sim 30 \text{ meV}$ @ 1 keV
- collimated-light PGM optical scheme

• flux up to 1.5x10¹³ ph/s/0.01%BW: factor of 10 to 100 increase compared to best available beamlines ⇒ breakthrough of the cross-section problem

SX-ARPES Endstation *@* **ADRESS:** Geometry

• grazing incidence at 20° to increase photoyield (factor of 2 compared to 45°)



- horizontal rotation axis to balance the vertical (<20 µm) and horizontal (74µm) light footprint
- rotatable analyzer: parallel slit
 orientation ⇒ symmetry analysis of the valence states

V.S., J. Synchr. Rad **20** (2013) analyser slit orientation sample rotation by tilt light beam α primary sample rotation PDA

manipulator axis

3D k-vector definition of SX-ARPES: Bandstucture and Fermi surface of VSe₂

- quasi-2D structure with weaker interlayer interaction
- significant 3D-lity due to Se $4p_z$ orbitals



- Experimental *E*(k)

- k_z by varying hv around 900 eV
- $\Delta E \sim 110 \text{ meV}$

- excellent statistics in a few min despite the cross-section loss (~1800 for V3*d* and 35 for Se 4*p* vs *hv*=50eV)
- intense and sharp structures $\Rightarrow e-ph$ scattering effects (spectral weight transfer to 3D-DOS and **k**-broadening) are insignificant at our *T*=10.7K despite low *T*_D=220K
- significant 3D-lity of Se $4p_z$ orbitals
- agreement with GGA-DFT (*P. Blaha, TU Wien*)



- Experimental 3D Fermi surface of VSe₂



• extraordinary clarity of the experimental data (no image enhancement): Sharp definition of 3D wavevector and regular matrix elements in soft-X-ray energies

• agreement with GGA-DFT (P. Blaha, TU Wien)

- Origin of 3-dimensional CDWs
- Unusual 3-dimensionality of CDWs:

 $\mathbf{q}^{\text{CDW}} = \mathbf{q}_{//} \mathbf{q}_{z} (q_{z} \sim k_{z}^{\text{BZ}/3})$



- Perpendicular FS cut in MLL'M' plane



• 3D warping to support nesting close q_z^{CDW}

- V.S. et al., PRL 109 (2012) 086401



• Autocorrelation peak at $\mathbf{q}_{//}^{\text{CDW}}$ and shifted to q_z^{CDW} by commensurization

Penetrating ability of SX-ARPES: Band structure of GaAs through amorphous As layer



M. Kobayashi et al (SLS); samples: Uni Tokyo

• large λ required: Soft-X-ray ARPES



hv = 287 eV



hv = 892 eV

HH

LH

SO



- acquisition time 3 min
- GaAs signal piles up with hv
- New diagnostics tool for MBE grown films: Applications in microelectronics
- M. Kobayashi et al., Appl. Phys. Lett. 101 (2012) 242103

Ferromagnetism of diluted magnetic semiconductor GaMnAs



- Role of impurity vs band states in the ferromagnetism of GaMnAs:
- does Mn form an impurity band?
- energy alignment of the Mn impurity band?
- hybridization with the host GaAs bands?

• HAXPES study in A.X. Gray *et al*, Nature Mat. 11 (2012) 957: Mn weight below E_F ; Ferromagnetism as a combination of the two models

Elemental specificity of SX-ARPES: Resonant ARPES of diluted magnetic semiconductor GaMnAs



M. Kobayashi et al (SLS); samples: Uni Tokyo

- Mn concentration only 2.5% of Ga
 ⇒ hard to see unless resonantly enhance Mn 3d weight
- Resonance on ferromagnetic XAS peak ⇒ ferromagnetic non-dispersive Mn 3*d* impurity band just below the VBM



- Linear dichroism





• Intensity at the ferromagnetic resonance \Rightarrow Mn 3*d* impurity band hybridizes with LH but only weakly with HH band

Ferromagnetism of diluted magnetic semiconductor GaMnAs



• Occupied Mn 3*d* impurity band hybridizing with GaAs host band



• Ferromagnetism induced by GaAs mediated exchange between Mn atoms

• Description starting from the Anderson impurity model

- M. Kobayashi et al., http://arxiv.org/abs/1302.0063 (submitted to Phys. Rev. Lett.)

Buried interfaces: Resonant SX-ARPES of LaAlO₃/SrTiO₃



2DEG at the LAO/STO interface:

- electrons delivered by Ti³⁺ ions
- Critical LAO thickness > 4 u.c.
 ⇒ SX-ARPES required

• Idea: Use Ti³⁺ **resonant** SX-ARPES to enhance the 2DEG signal

Depth Profiling of 2DEG at the LaAlO₃/SrTiO₃ interface



C. Cancellieri, M. Reinle-Schmitt et al; samples: Uni Geneve

- measurements @ $RT \Rightarrow$ averaging in k-space
- comparison of insulating (3 uc LAO) and conducting (6 uc LAO) samples



• Angle-dependent XPS to resolve the 2DEG depth profile



• k-integration due to RT

$$I(\theta) = G(\theta, \phi) \int_0^\infty R(z) e^{-z/\lambda \cos \theta} \,\mathrm{d}z$$

• $I(\theta)$ = Laplace transform of R(z)



• 2DEG is located within **1.0±0.3 u.c.** on the STO side of the interface

- C. Cancellieri et al., PRL 110 (2013) 137601

Fermi surface and bandstructure of the interface states

- T = 11 K to suppress *e-ph* scattering
- •FS mapping at 2*p* resonance of Ti^{3+} at hv = 460.2 eV
- •Experimental $\Delta E \sim 80 \text{ meV}$



- FS shape of crossed 3d_{xy}-like cigars (G. Berner *et al*, Phys. Rev. Lett. **110** (2013) 247601
 talk of M. Sing; N. Plumb *et al*, arXiv:1304.5948)
- different FS sheets depending on $\mathbf{K}_{//}$ and polarization







A. Filippetti, P. Ghosez & D. Fontaine

• composite interface state with subbands of different symmetries

• different sample preparations:

- Luttinger count of the FS area follows n_e from transport properties \Rightarrow coherent interface conductivity with insignificant contribution of ox-vacancies

- interface charge varies and differs from 0.5 e/u.c. (deviations from both structural deformation and polar catastrophe model)

- C. Cancellieri et al., arXiv:1307.6943 (2013)

Comparison of VUV- and SX-ARPES

	VUV-ARPES	SX-ARPES
ΔE	meV-scale: quasiparticle interactions	tens-of-meV scale global valence band
probing depth λ	few Å: simple surfaces	~ 15 Å: bulk and buried heterostructures
k _z definition	$\Delta k_z \sim k_z^{BZ}$ and non-FE final states: mostly 2D systems	$\Delta k_z \ll k_z^{BZ}$ and FE final states: 3D systems

- SX-ARPES spectroscopic properties:
- 3D bulk band structure (FS and CDWs in VSe₂, FS in perovskite LSMO...)
- Enhanced probing depth: Band structure of GaAs behind thick cap layer ...
- Elemental specificity through resonant photoemission: Ferromagnetic impurity band in GaMnAs, depth localization and Fermi surface of LAO/STO ...
- Depth profiling with standing X-ray waves excited ARPES

• Flux performance of ADRESS **⇒ From 3D materials to buried heterostructures**



SX-ARPES team













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Collaborators at SLS

External collaborators













T. Schmitt M. Shi L. Patthey (RIXS) (SIS beamline) (now SwissFEL)

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